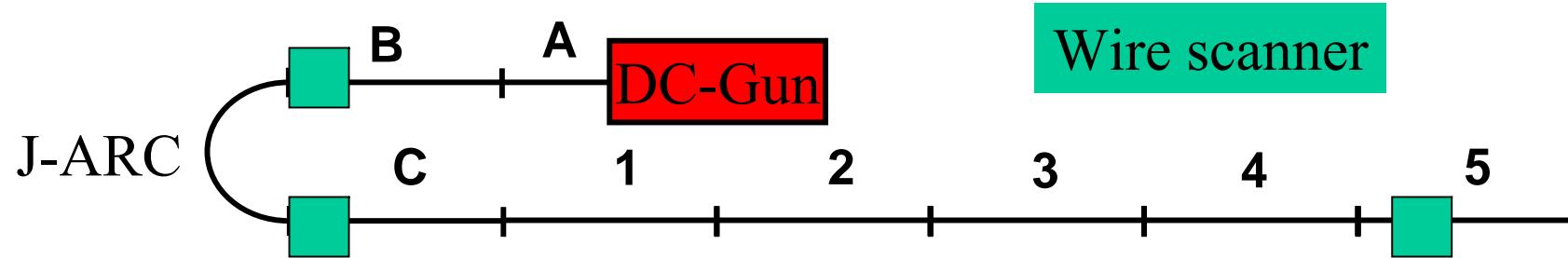


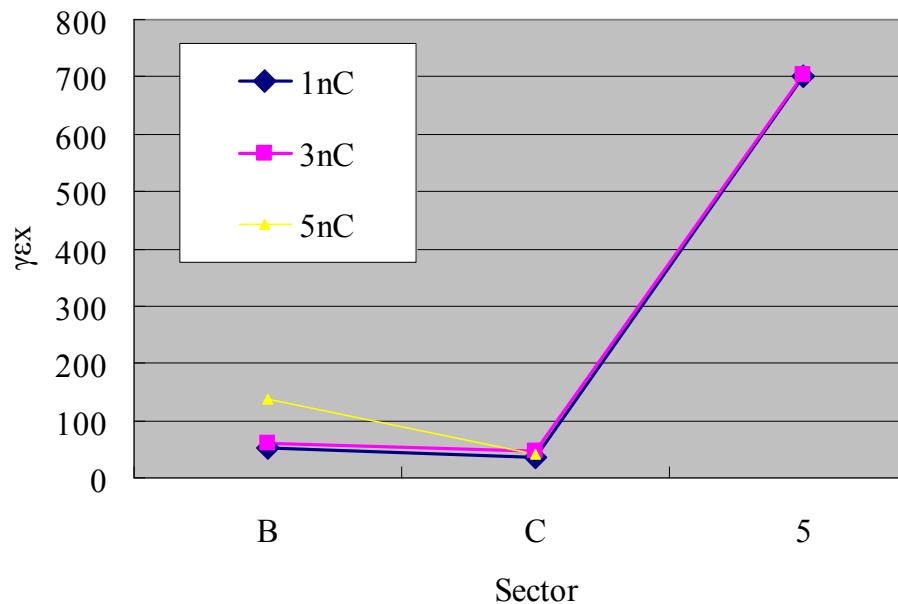
# Emittance Preservation in Linac

2011.02.07 Super KEKB Review

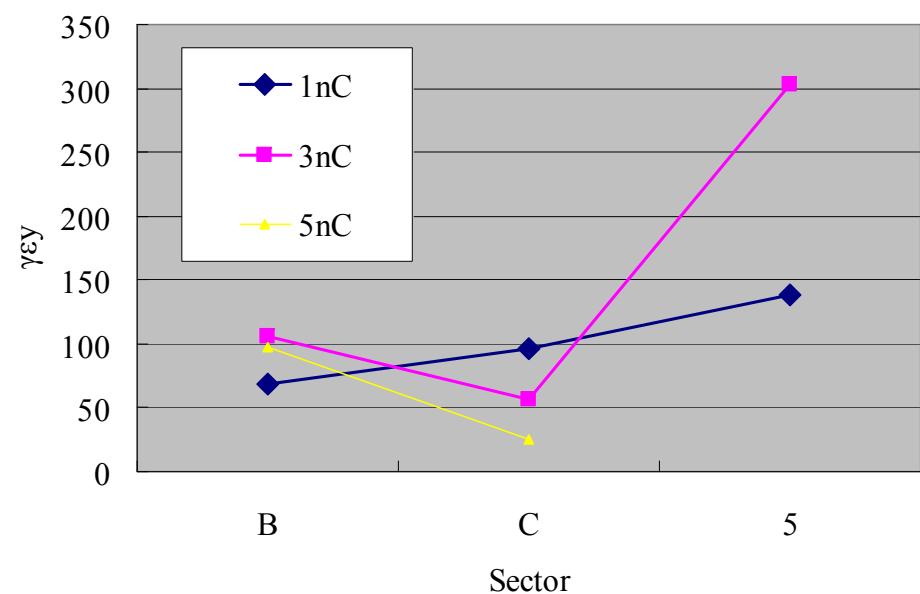
# Emittance Measurement @2009.07.01



Horizontal Emittance



Vertical Emittance



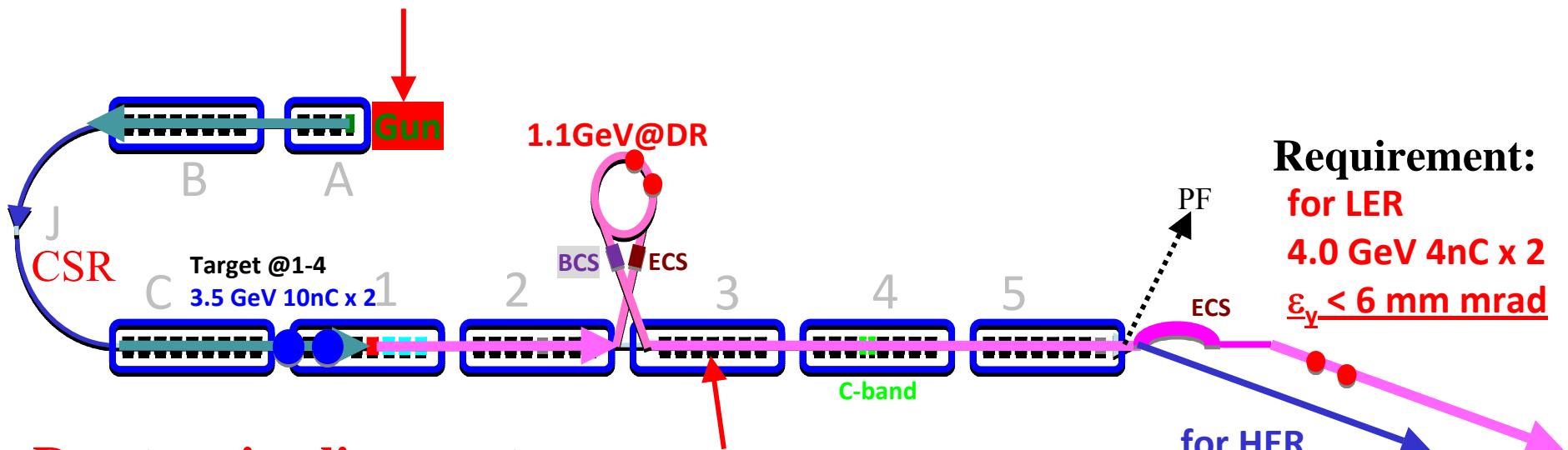
Initial emittance looks low considering  $\phi 16$  big cathode.

Problem is emittance growth.

Machine study from 2010/10

# Overview of emittance source and growth

Longer bunch can reduce space charge effect inside RF-Gun and also CSR at J-ARC.



Due to mis-alignment:  
- Dispersion  
- Short range wakefield

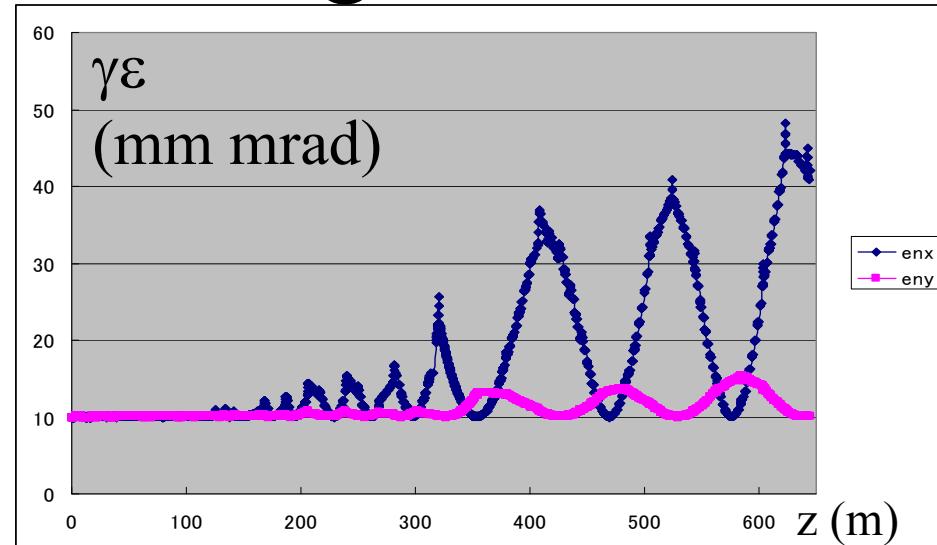
One feed coupler (x480)  
causes of RF emittance.  
( $\Delta\gamma\varepsilon \sim 1.2 \text{ mm mrad}$  is estimated)

Current charge & emittance:  
 $e^- : 1 \text{ nC}, 300 \text{ mm mrad}$   
 $e^+ : 1 \text{ nC}, 2100 \text{ mm mrad}$

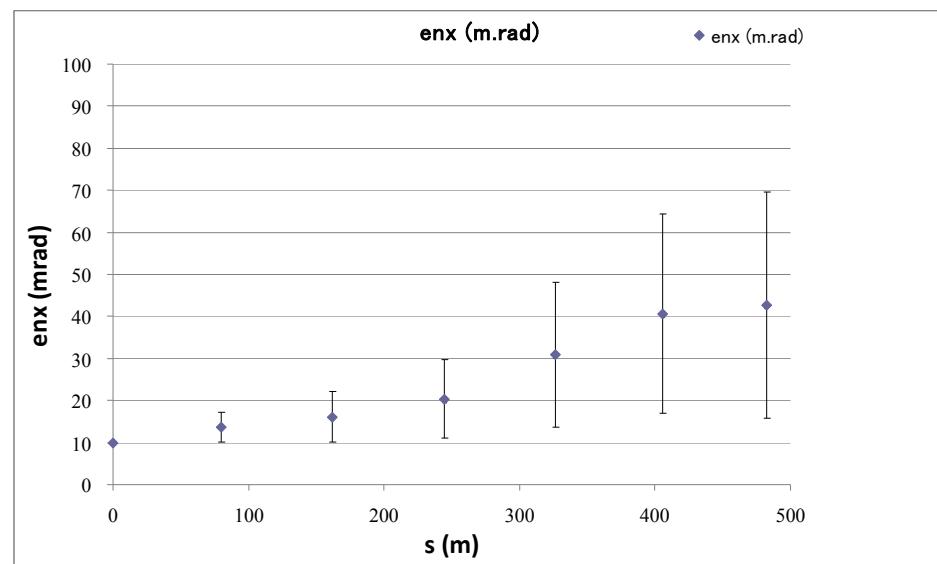
# Apparent emittance growth due to Dispersion and Short Range Wakefield

- Mis-alignment :  $\sigma_x = 0.5$  mm
- Initial emittance = 10 mm mrad
- $\delta_p$  : 0.1 %,  $\sigma_z$  : 1mm

Dispersion  
(only from  $\eta_x$ )



[Short Range Wakefield]  
- Charge : 5 nC



# Emittance Compensation $\leftrightarrow$ Alignment

Alignment tolerance:

becomes severe without compensation

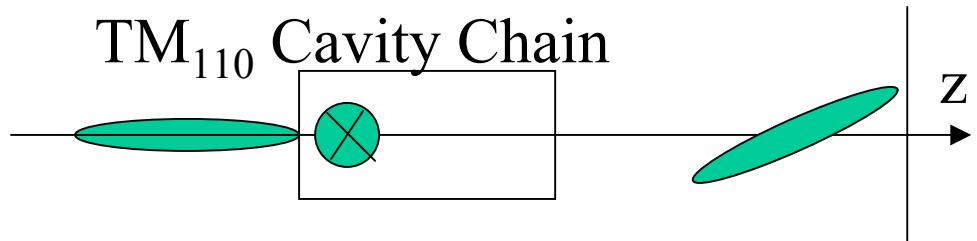
$\Rightarrow$  Compensation is required.

should be determined by second order effect and compensation error.

→ Machine & simulation study of emittance source.

- Dispersion : compensated in BT line.
- Short range wakefield : Initial offset
  - Monitoring using RF-Deflector is required.
- RF Emittance : RF-Deflector can compensate
- CSR : longer bunch length.

RF-Deflector  $\Rightarrow$  bunch slice emittance

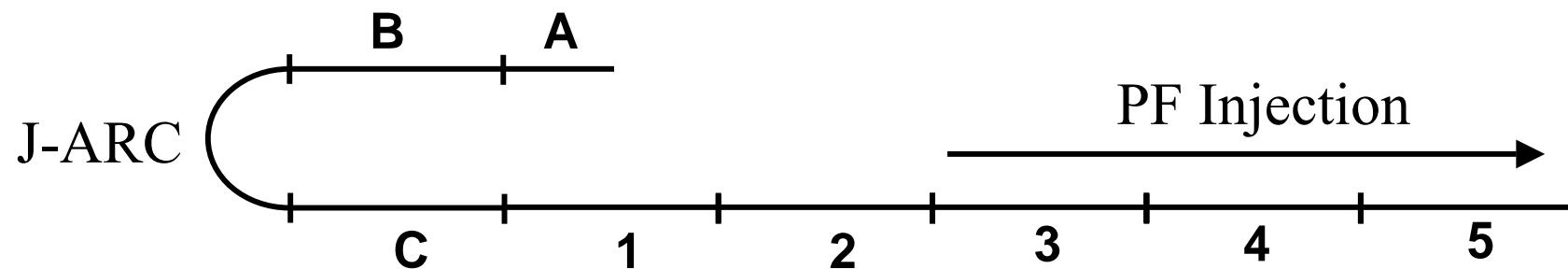


# Machine study

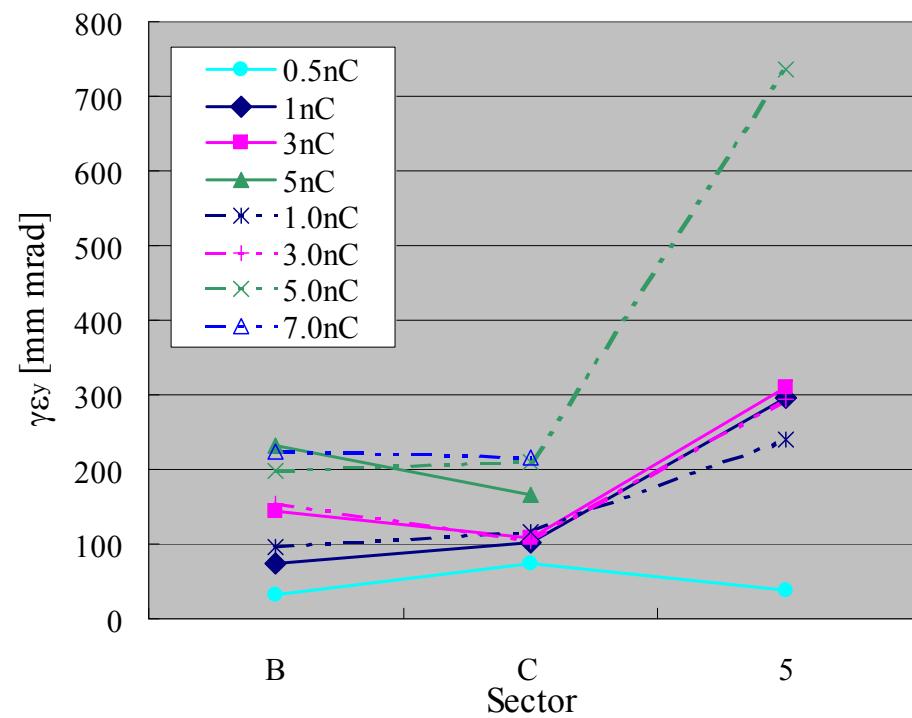
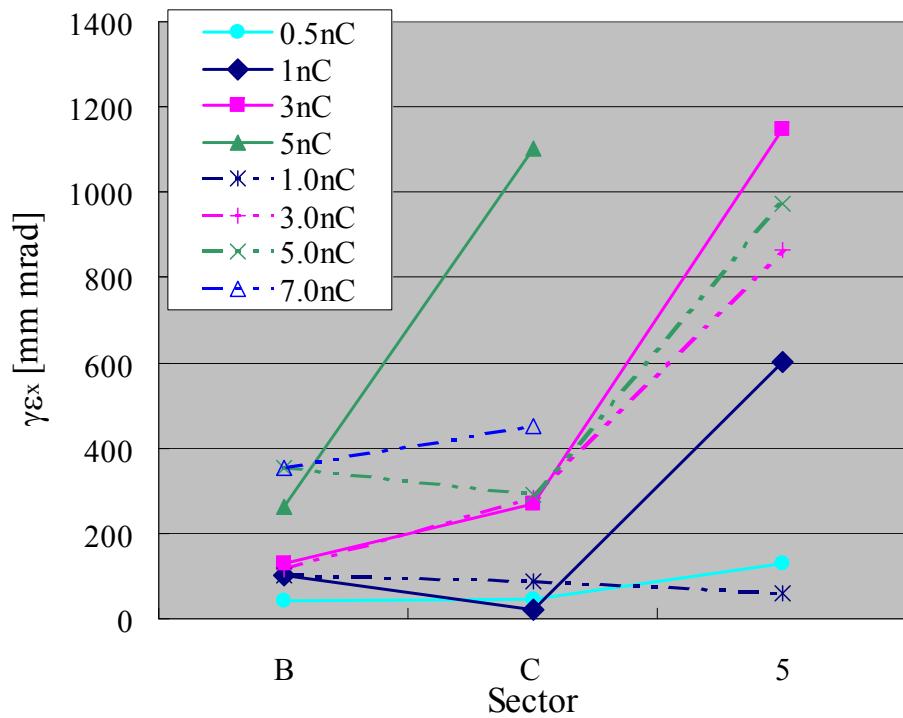
from 2010.10

# Machine study

- Emittance growth measurement
  - Charge dependence
  - Optics dependence
- $R_{16}, R_{36}$  measurement
- Response orbit measurement
  - Beam based alignment
  - Dispersion calculation



# Emittance measurement

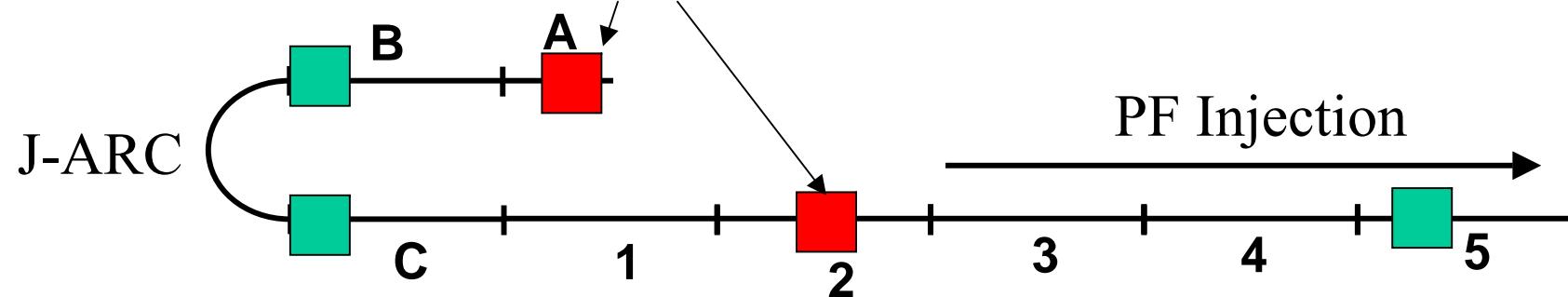


# Emittance measurement

Improvement of emittance measurement will be required:

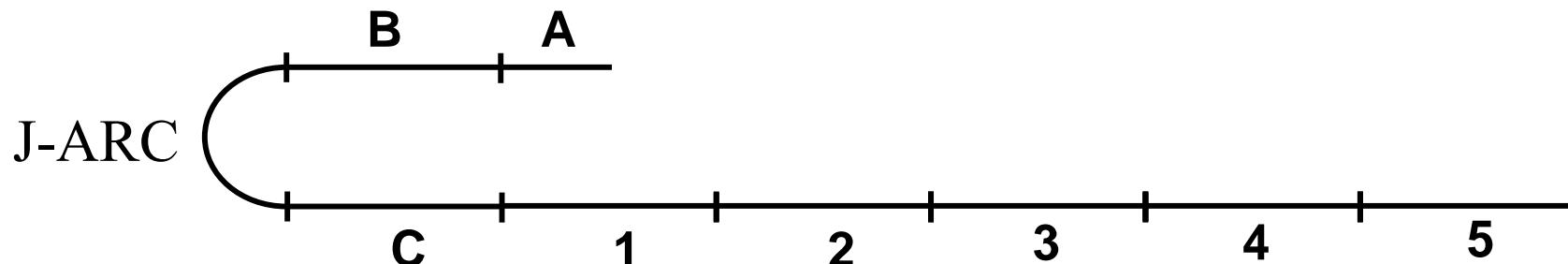
- Optimize phase advance during PF injection.  
=> Use injection intervals to change Q-magnets.
- RF-gun installation to obtain lower emittance.

Wire scanner should install more:



# Dispersion ( $R_{16}, R_{36}$ )

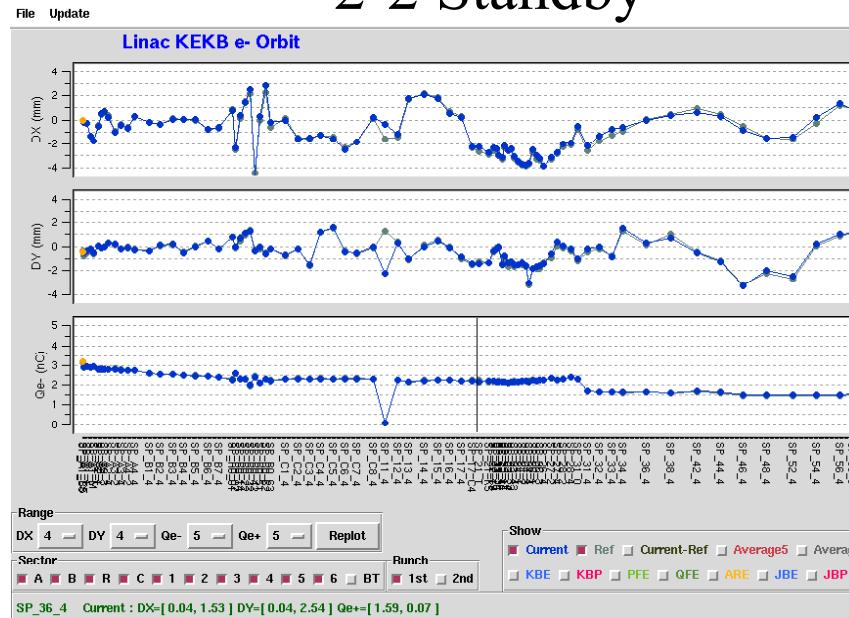
- Emittance growth was observed at 1 nC.
- Large dispersion was measured at sector 5.
- Dispersion leak from J-ARC is small by comparing energy change before and after ARC section
- 3~5 sector has small dispersion  
→ Determine the dispersion source



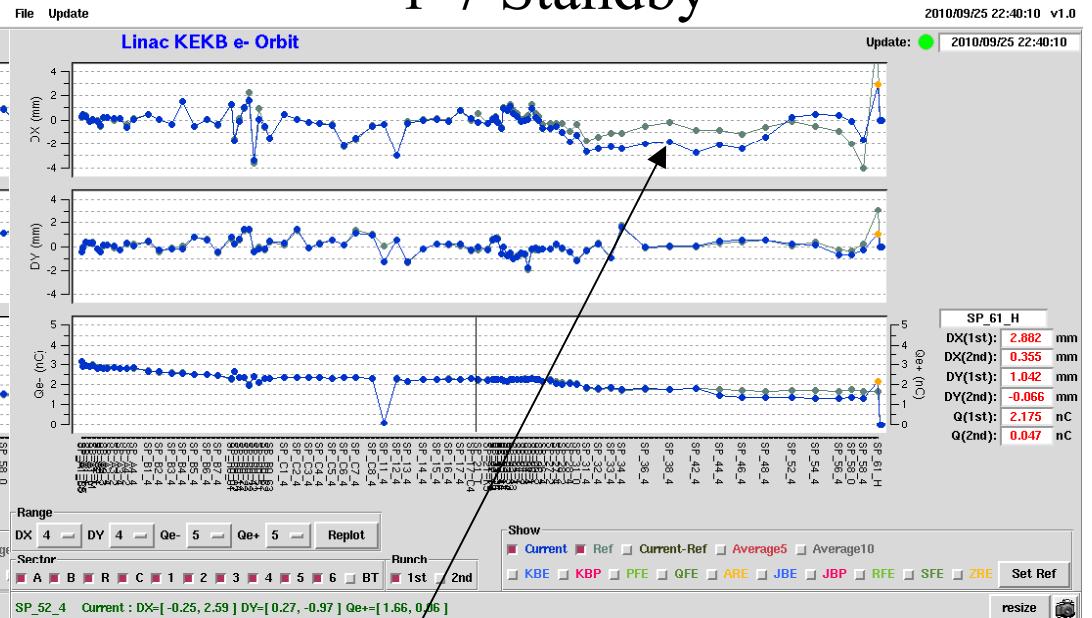
# Horizontal Dispersion (One by one unit standby)

- 1-7 to 2-2 has horizontal dispersion source

2-2 Standby



1-7 Standby

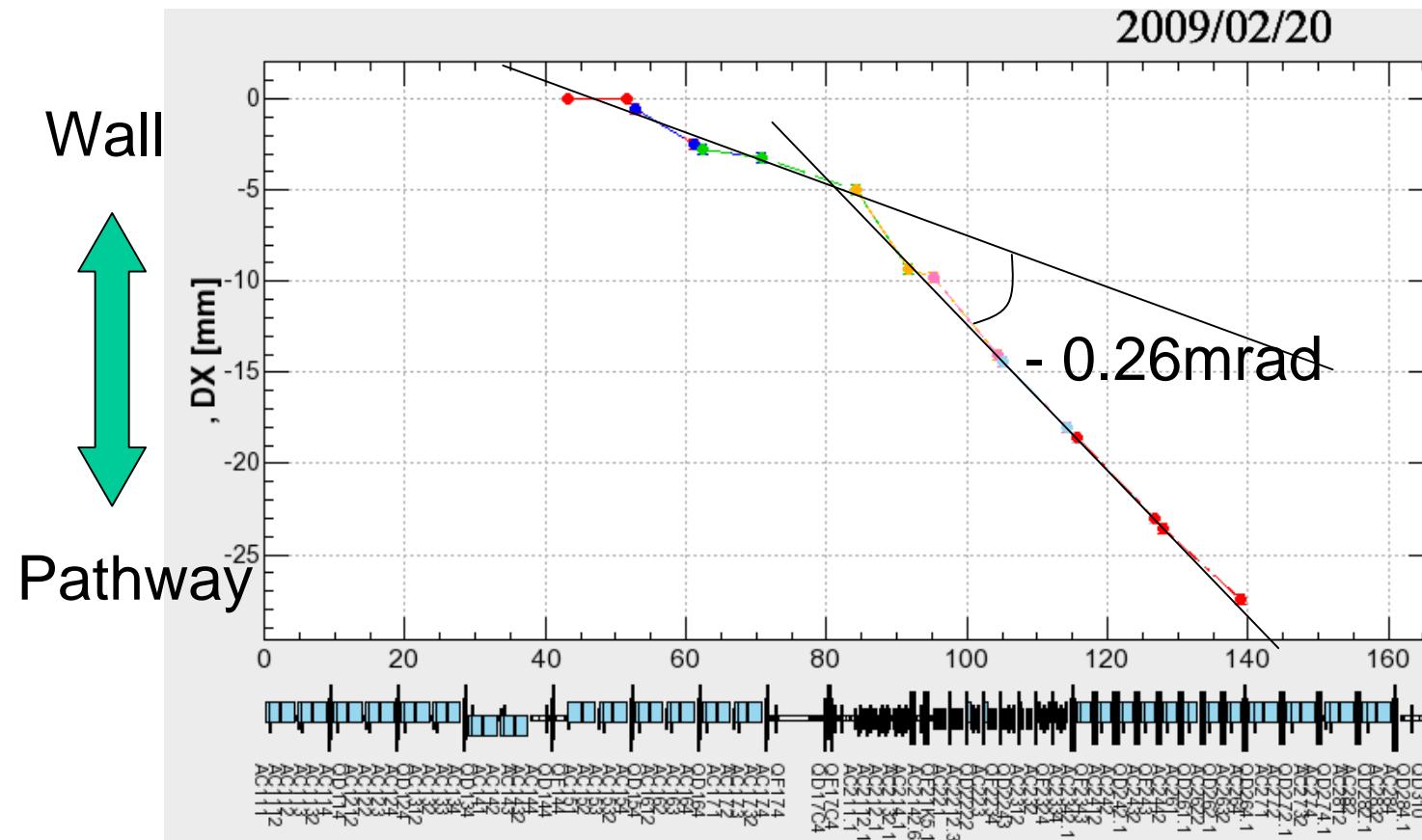


$$\Delta p = 140 \text{ MeV} (\text{p}=4 \text{ GeV}) \rightarrow R_{16} = 50 \text{ mm}$$

Kink at 2-1 was observed before.

# Kink of 2-1

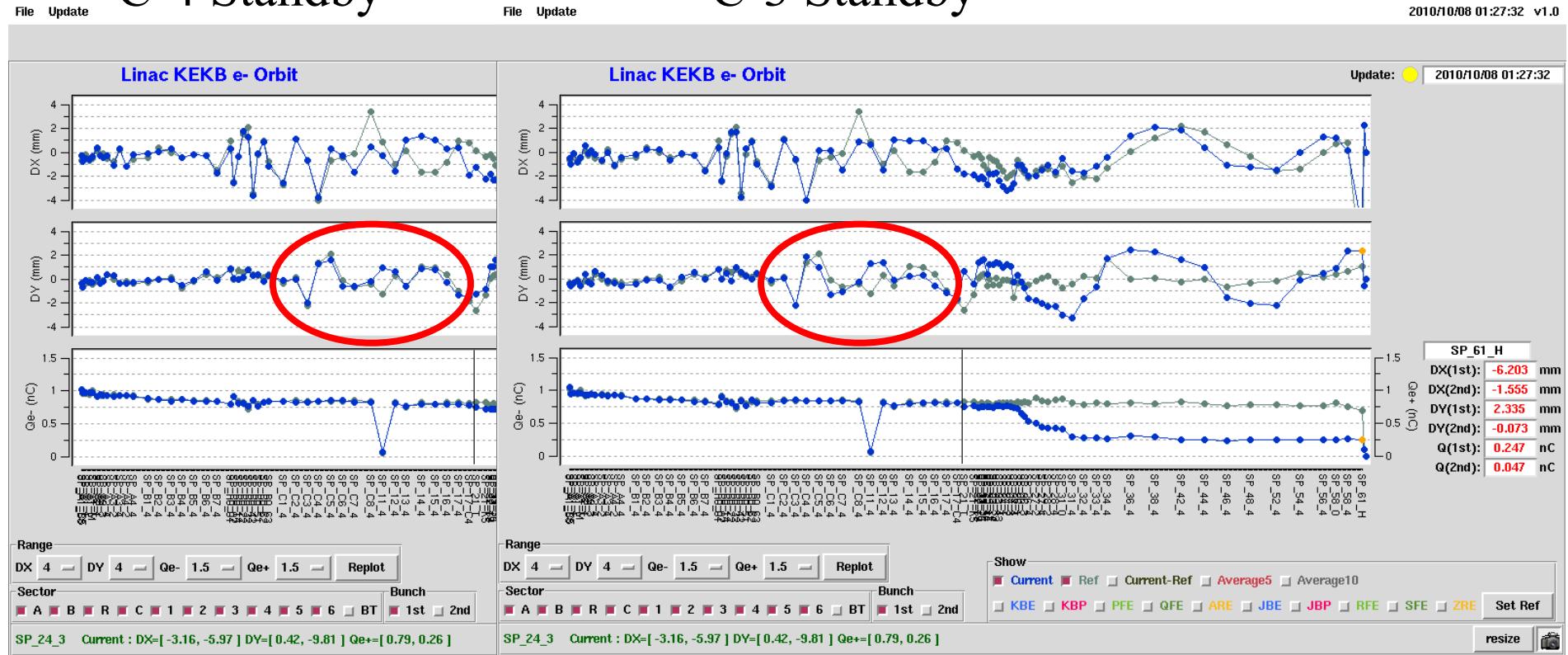
Wall



# Vertical Dispersion (One by one standby)

C-4 Standby

C-3 Standby

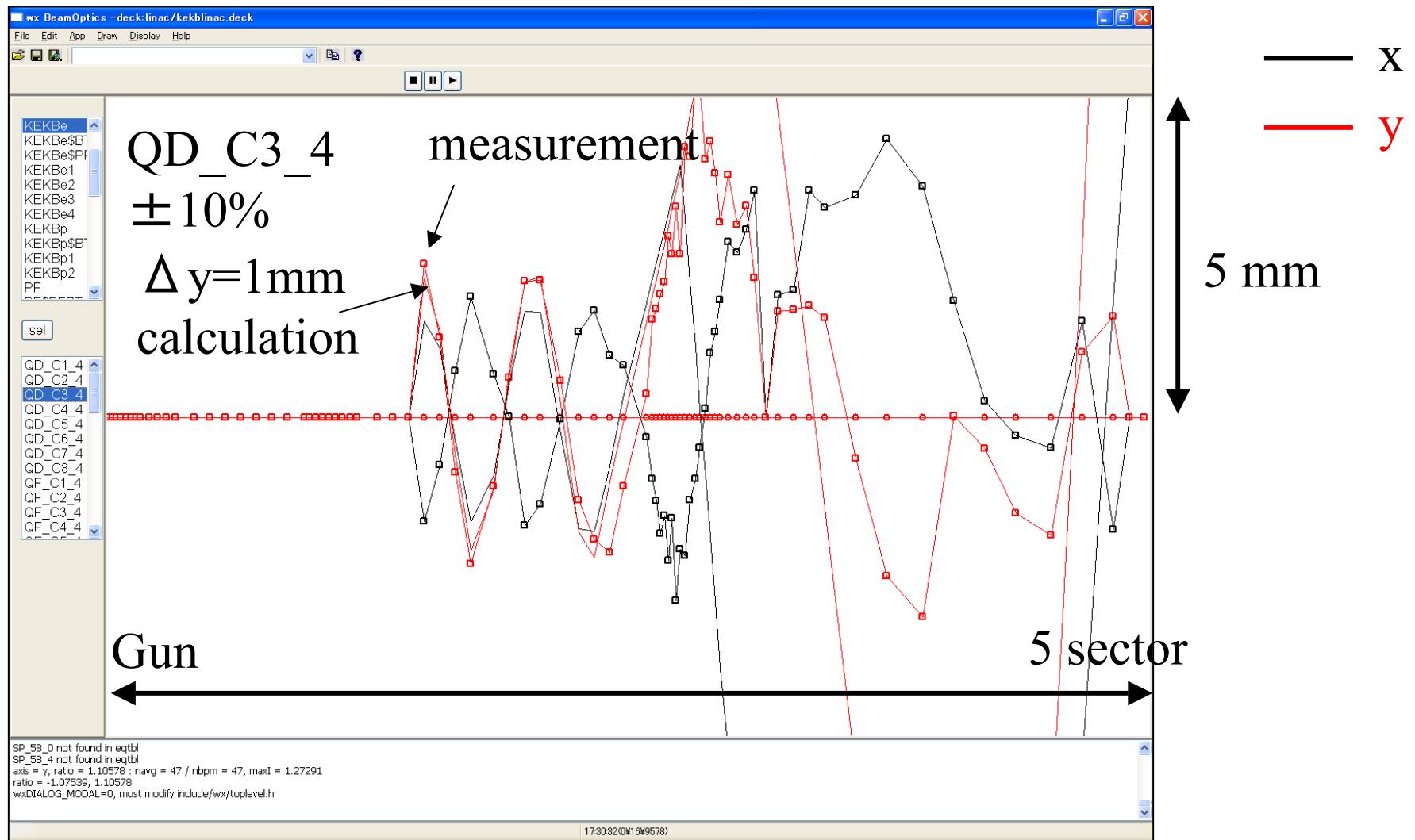


→ Building connection between C3 and C4 unit causes 1 mm mis-alignment.

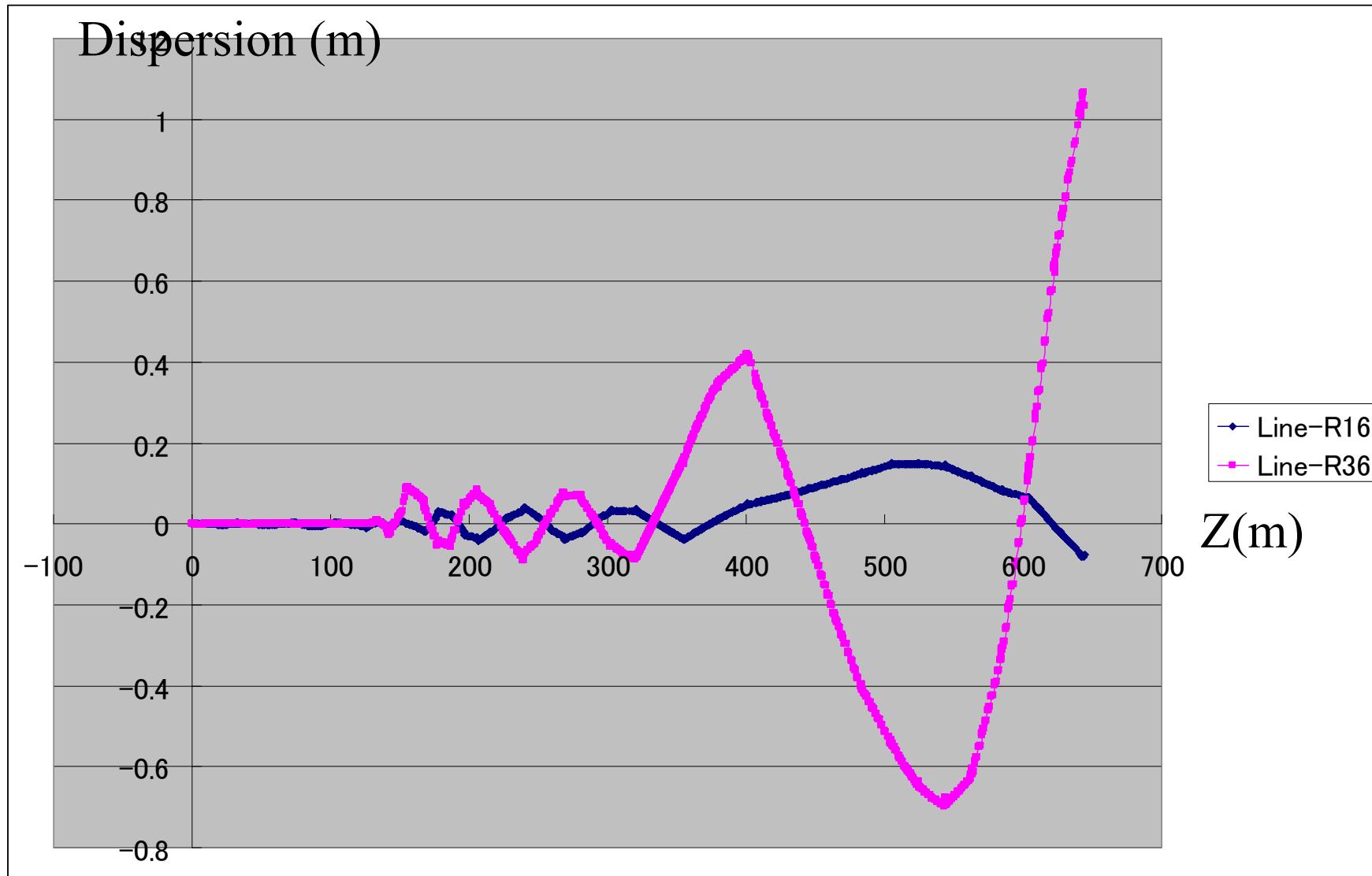
Dispersion source is almost found, but so large dispersion (200mm)

# Response measurement

- All magnets : Q, Steering, Sextupole



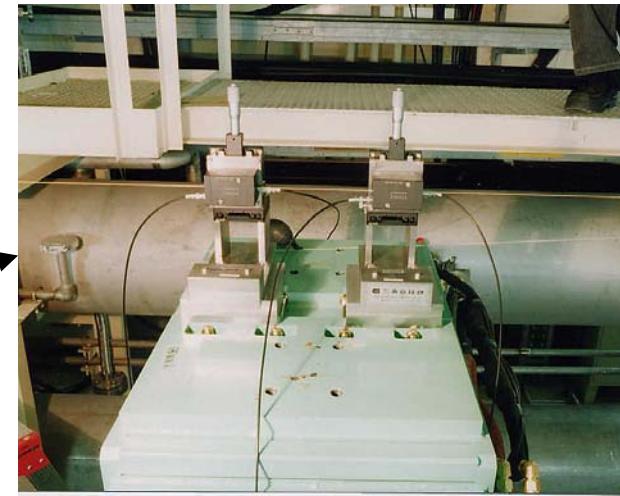
# Calculated dispersion from response measurement



# Emittance preservation and compensation

# Alignment

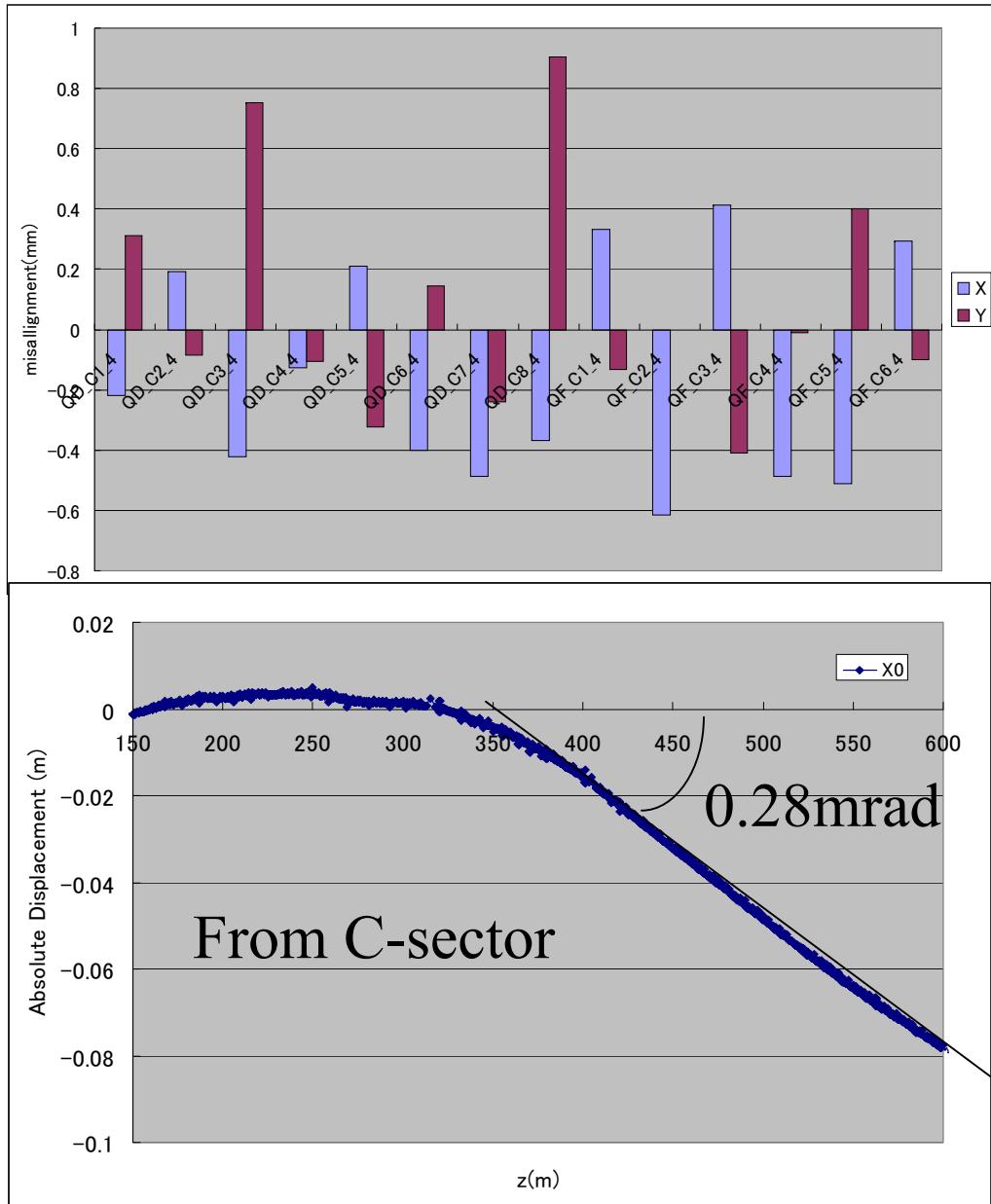
- Conventional alignment
  - Wire positioning for horizontal
  - Hydraulic leveling for vertical
- Beam based alignment
  - Response from all magnets
- Laser alignment
  - R&D for continuous measurement.



2011.04 => Alignment

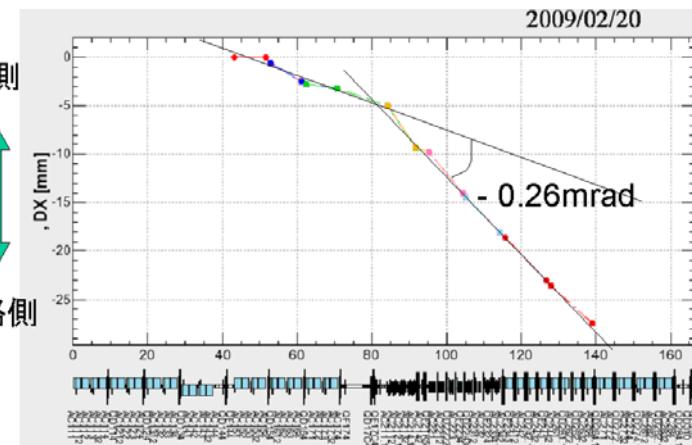


# Beam based alignment

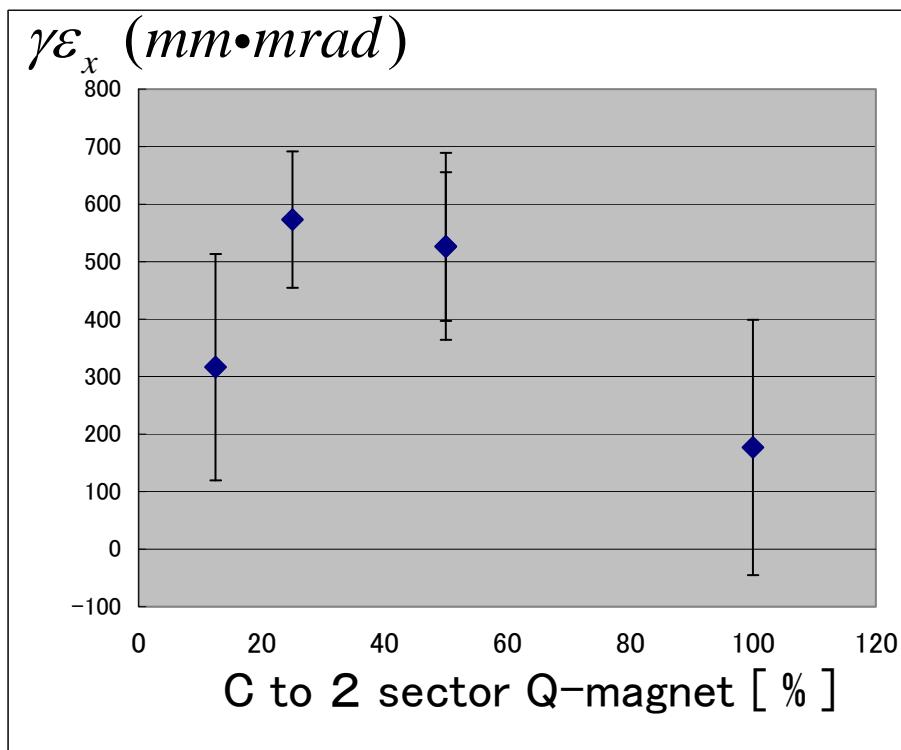
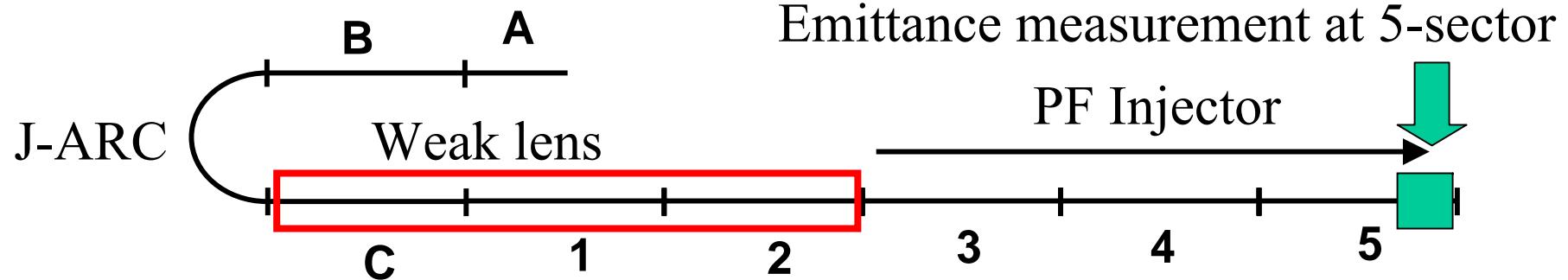


C-sector

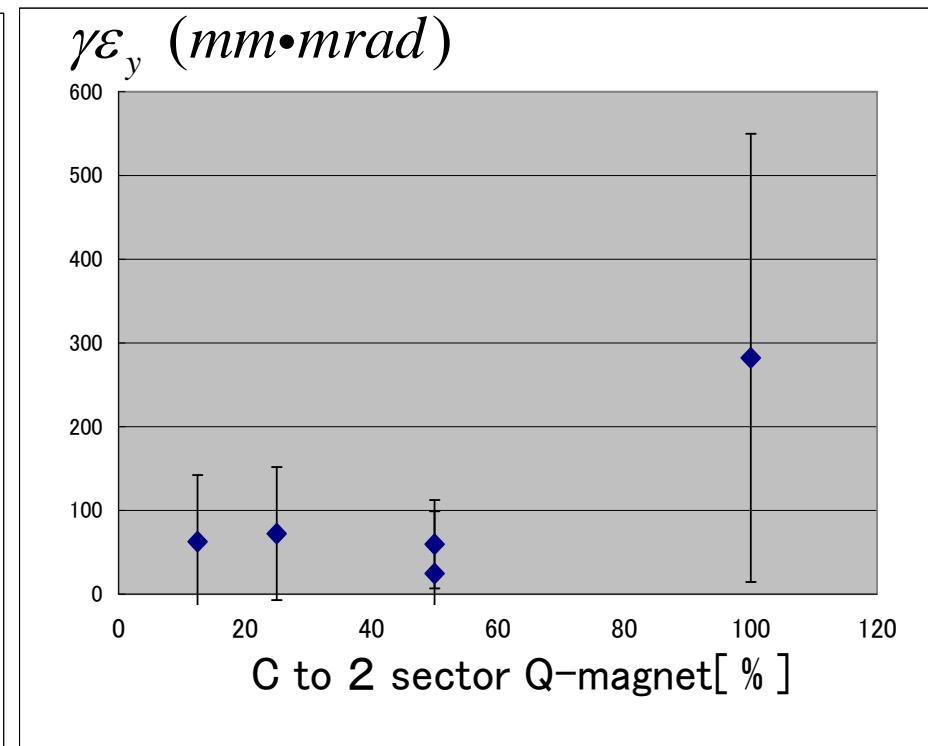
壁側  
↑  
↓  
通路側



# Dispersion reduction (Weak lens)

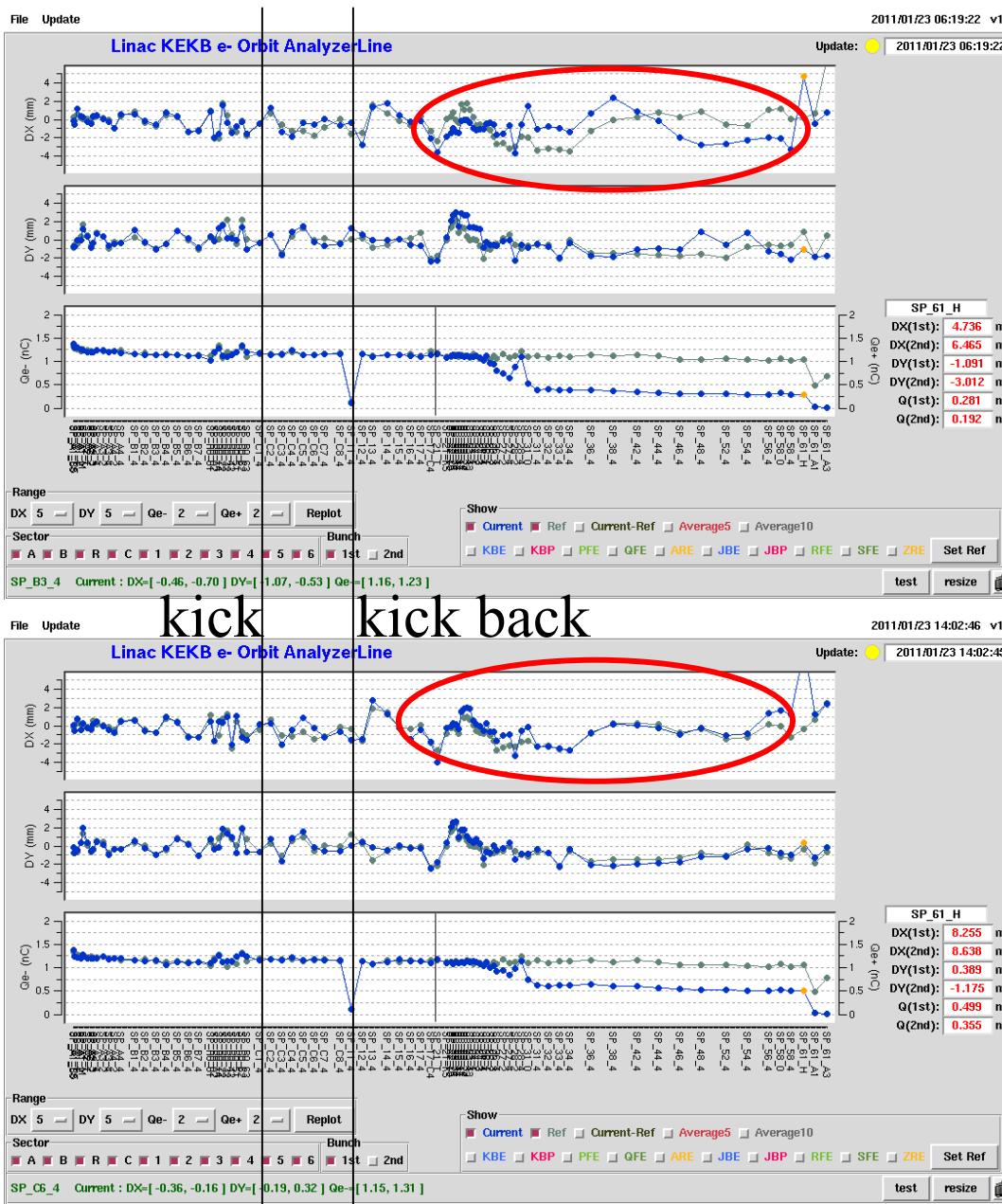


Kink at 2-1 is dominant ?



Quadrupole mis-alignment  
may be dominant.

# Dispersion compensation by beam orbit



Reference (green line)  
C-1 Standby (blue line)

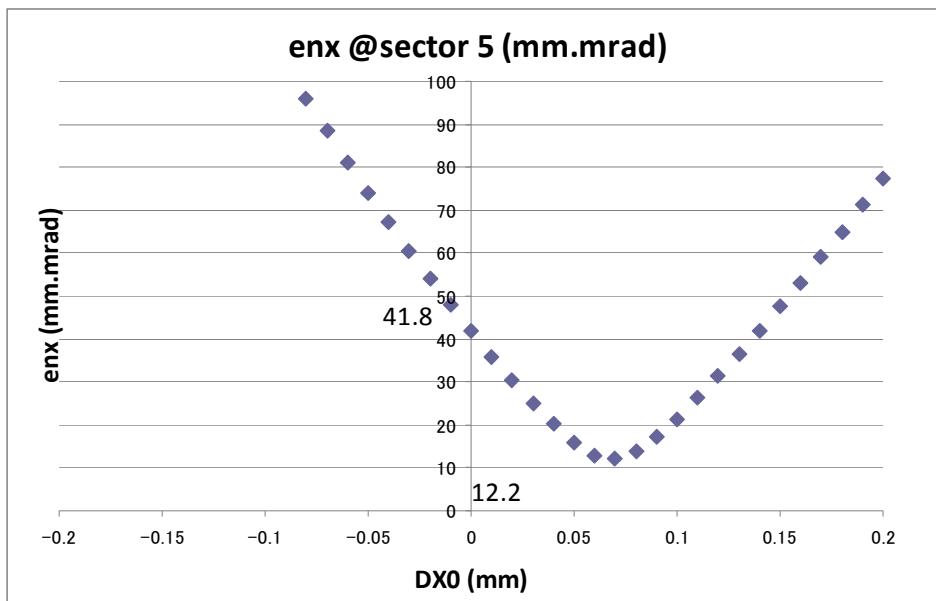
# Short range wakefield (simulated using ELEGANT)

Charge : 5 nC

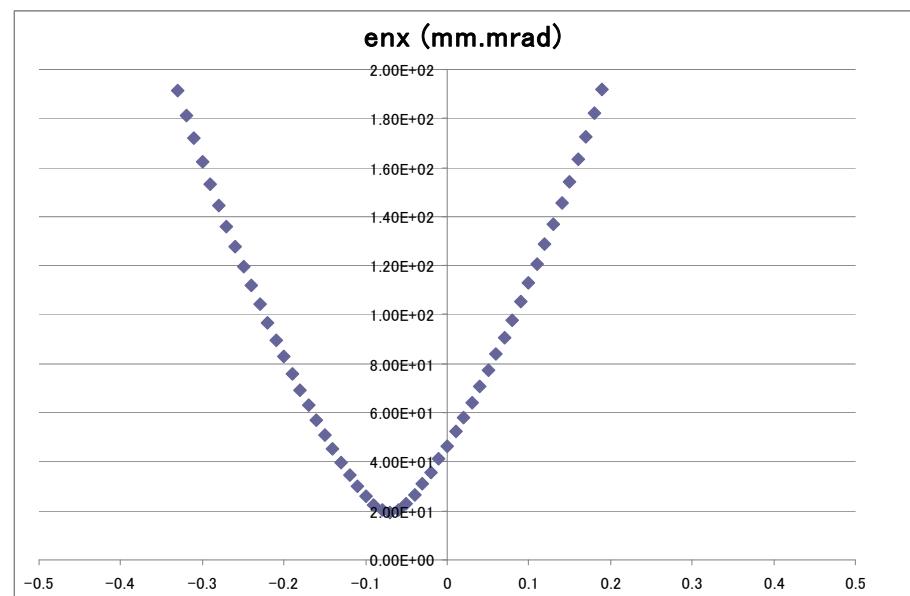
Mis-alignment :  $\sigma_x = 0.5\text{mm}$

Initial emittance = 10 mm mrad

$\delta_p$  : 0.1 %,  $\sigma_z$  : 1mm



Initial offset (mm)



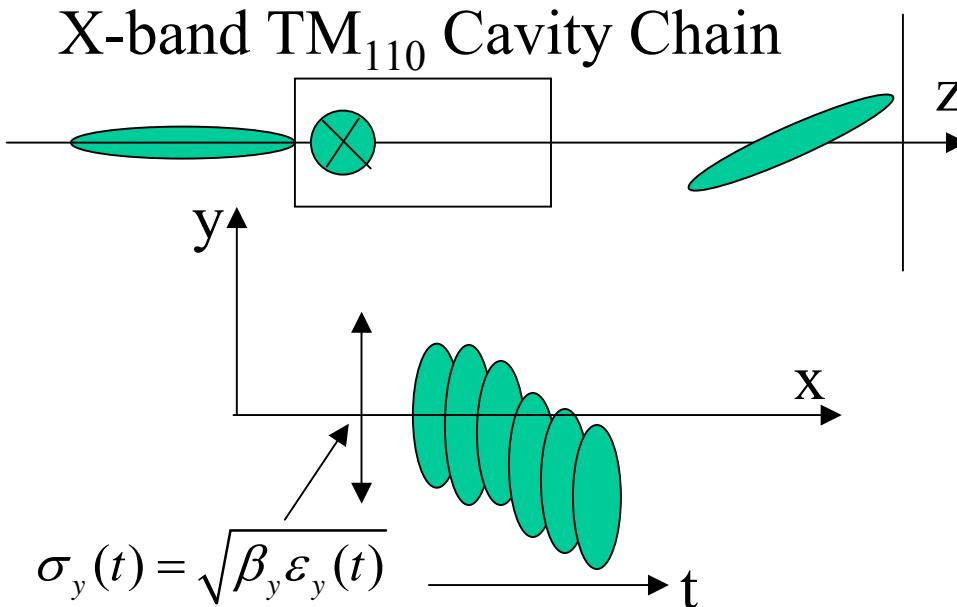
Initial offset (mm)

# Beam diagnostic station

RF-Deflector => Longitudinal slice observation.

- Compensation of RF-Emittance

- Measurement of short range wakefield => Initial offset



$$\Delta x_{\text{screen}} = \sqrt{\beta_{\text{deflector}} \beta_{\text{screen}}} \left( \frac{eV_{\text{deflector}} \omega_{\text{RF}} \Delta t}{E_{\text{beam}}} \right) \sin\left(\phi_{\text{deflector} \rightarrow \text{screen}} = \frac{\pi}{2}\right)$$

$$\sigma_x = \sqrt{\beta_{\text{screen}} \epsilon_{\text{screen}}}$$

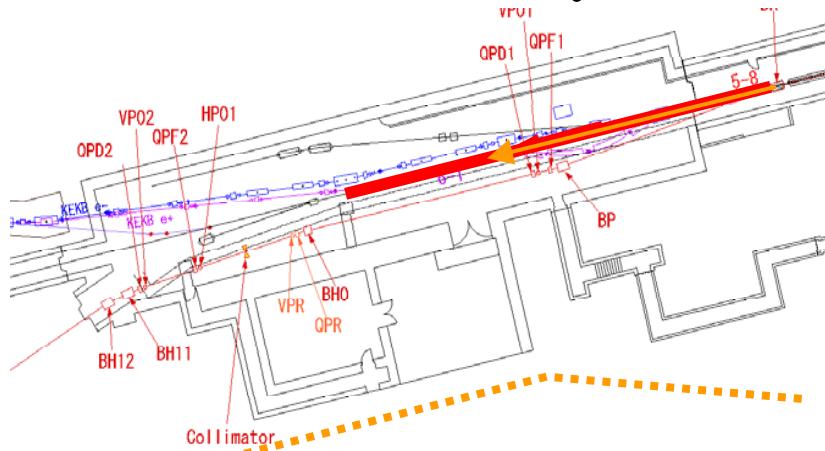
$$\Delta x_{\text{screen}} / \sigma_x = \sqrt{\frac{\beta_{\text{deflector}}}{\epsilon_{\text{screen}}}} \left( \frac{eV_{\text{deflector}} \omega_{\text{RF}} \Delta t}{E_{\text{beam}}} \right)$$

$$V_{\text{deflector}} = 20\text{MV}, f_{\text{RF}} = 2.856\text{GHz}, \Delta t = 1\text{ps}, \beta_{\text{deflector}} = 10\text{m}$$

$\rightarrow \Delta x_{\text{screen}} / \sigma_x = 4$

$$V_{\text{deflector}} = 50\text{MV}, f_{\text{RF}} = 11.424\text{GHz}, \Delta t = 1\text{ps}, \beta_{\text{deflector}} = 10\text{m}$$

$\rightarrow \Delta x_{\text{screen}} / \sigma_x = 40$



Placed at 3<sup>rd</sup> switch yard

# Summary and plan for machine study

FY2010:

- Improvement for machine study:
  - Agreement of measured and simulated optics.
  - Emittance measurement.
  - Continuous machine study during PF injection.
- Dispersion:
  - Both of measurement and simulation are proceeding.
  - Determine cancellation method as soon as possible.
- Determine alignment tolerance by simulation.

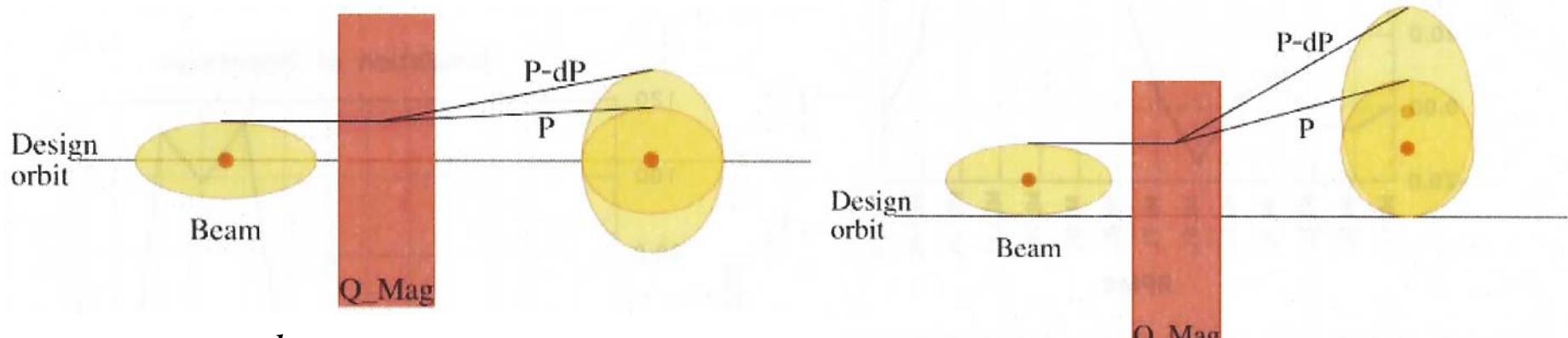
FY2011:

- Alignment (Beam-based & Conventional method)
- Installation of RF-Gun.
  - => Emittance measurement using lower emittance beam
- Development of RF-Deflector
  - to measure short range wakefield and compensate RF emittance
  - => Install by FY2012
- Installation of wire scanner.

- Final Target:
  - Multi-line beam optics control software development
  - Continuous emittance preservation corresponding to emittance measurement during operation.
- Emittance preservation
  - Research for emittance growth
    - Dispersion (Yoshida, Iida)
    - RF emittance (Matsumoto, Yoshida)
    - Short range wakefield ( Zang, Sato, Iida( $e^+$ ), Yoshida )
    - CSR (Zang, Yoshida)
  - Hardware development for beam diagnostics and compensation
    - X-band RF deflector (Matsumoto, Yoshida)
    - 3<sup>rd</sup> switch yard – Beam diagnostic station (Sato, Yoshida)
    - Q-magnet with active mover
    - Pulse steering (Kamitani)
  - Alignment
    - Beam based alignment(Yoshida), Laser alignment(Suwada) / Wire + Water pipe (Sugawara)

# Appendix: Emittance source

# Apparent emittance growth caused by dispersion



$$K = \frac{eg}{p}, \quad dx = \frac{dp}{p} \eta_x$$

$$\eta'(s) = 0$$

$$\Delta\epsilon_{dispersion} = \sqrt{\langle p_x^2 \rangle \langle x^2 \rangle - \langle p_x x \rangle^2} - \epsilon_0 = \sqrt{(\epsilon_0 \beta_x + (\eta \delta)^2)(\epsilon_0 \gamma_x + (\eta' \delta)^2) - (\epsilon_0 \alpha_x + \eta \eta' \delta^2)^2} - \epsilon_0$$

$$(\alpha = 0, \beta \gamma = 1 \rightarrow \gamma = \frac{1}{\beta})$$

$$\approx \frac{\eta(s)^2 \delta(s)^2}{2 \langle \beta \rangle} \quad \delta(s): \text{energy spread}$$

$$\delta \sim 0.1\%, \quad \beta \sim 50m$$

$$\gamma \Delta \epsilon \sim 0.016 \text{ mm} \cdot \text{mrad} \quad (\text{for } \eta \sim 10 \text{ mm})$$

$$\gamma \Delta \epsilon \sim 6.4 \text{ mm} \cdot \text{mrad} \quad (\text{for } \eta \sim 200 \text{ mm}) \quad \stackrel{<}{=} \text{ measured value}$$

$$x(s_B) = R_{11}x(s_A) + R_{12}x'(s_A) + R_{16}\delta(s_A)$$

$$\delta(s_B) = \delta(s_A) \quad \text{for given acceleration phase}$$

$$\delta(s_B) = \frac{p(s_A)}{p(s_A) + \Delta p} \delta(s_A) \quad \text{for a part of energy change}$$

$$\begin{pmatrix} R_{11} & \dots & R_{16} \\ \vdots & \ddots & \vdots \\ R_{61} & \dots & R_{66} \end{pmatrix} \begin{pmatrix} x \\ \vdots \\ \delta \end{pmatrix}$$

# RF emittance caused by coupler of accelerating structure

- Dipole, Quadrupole     $2 \sim 5 \times 10^{-5}$

$$E_z = E_0 \sin(\omega t) \sum a_n r^n \cos n\varphi$$

$$\Delta\epsilon_1 = \frac{eE_0 L}{2m_e c^2 \pi} a_1 \sigma_y \sigma_z$$

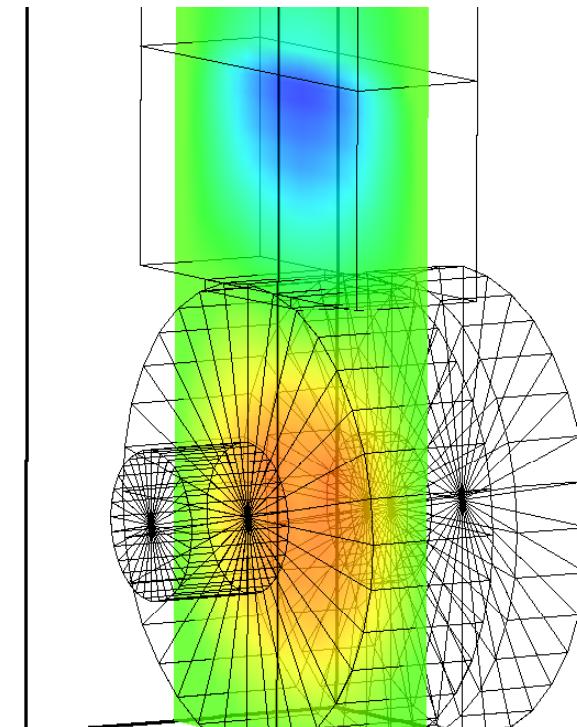
$$\Delta\epsilon_2 = \frac{eE_0 L}{2m_e c^2 \pi} 2a_2 \sigma_y^2 \sigma_z$$

$$E_0 = 17 \text{ MV/m}, \quad L = 35 \text{ mm},$$

$$\sigma_y = 2 \text{ mm}, \quad \sigma_z = 3 \text{ mm} = 10 \text{ ps}$$

$$a_1 = 5 \times 10^{-5}, \quad 480 \text{ cell}$$

$$\rightarrow \Delta\epsilon_1 = 80 \text{ nm} \rightarrow \gamma \Delta\epsilon = 1.2 \text{ mm} \cdot \text{mrad}$$



$a_1$  was determined by  
simulation

# Short Range Wakefield

$$\frac{d}{ds} \left( \gamma(s) \frac{d}{ds} x(z, s) \right) + \left( \frac{2\pi}{\lambda(s)} \right)^2 \gamma(s) x(z, s) = \frac{e^2 N_e}{m_0 c^2} \int_z^\infty \rho(z') W_t^\delta(z' - z, s) x(z', s) dz'$$

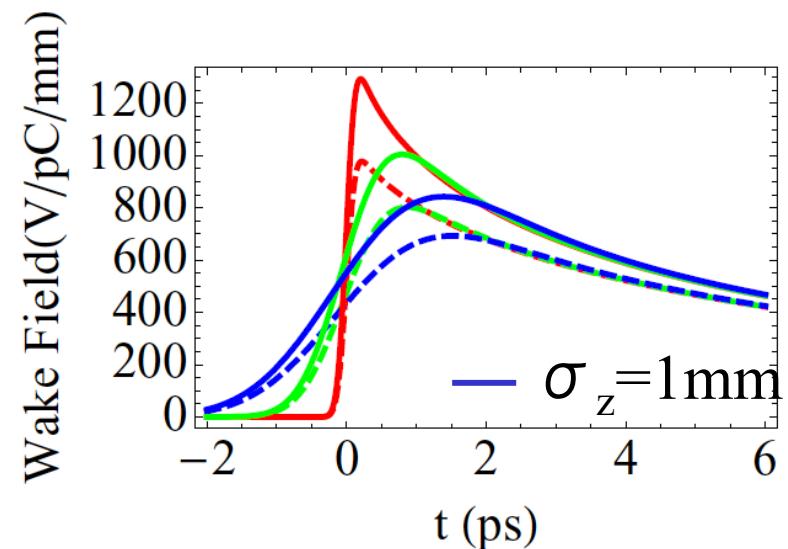
$$W_t(s) = \int \rho(s') W_t^\delta(s - s') ds' \propto \frac{\sqrt{\sigma_z}}{a^3}$$

$$\gamma \Delta \epsilon_x = \frac{\langle x_{alignment} \rangle^2 L \langle \beta \rangle}{2\gamma(0) G_f} \left( \frac{e^2 N_e W_t(z)}{m_0 c^2} \right)^2, \quad \gamma(s) = \gamma(0)(1 + G_f s)$$

$$\sigma_z \sim 10 \text{ ps} = 3 \text{ mm}, \quad \langle x_{alignment} \rangle = 0.1 \text{ mm}, \quad q = 5 \text{ nC}, \quad W_t^\delta(z) = z \times 3 \times 10^{15} \text{ V/C/m}^2$$

$$\gamma(0) = 4000, \quad G_f = 0.01 \quad (\text{from C sector})$$

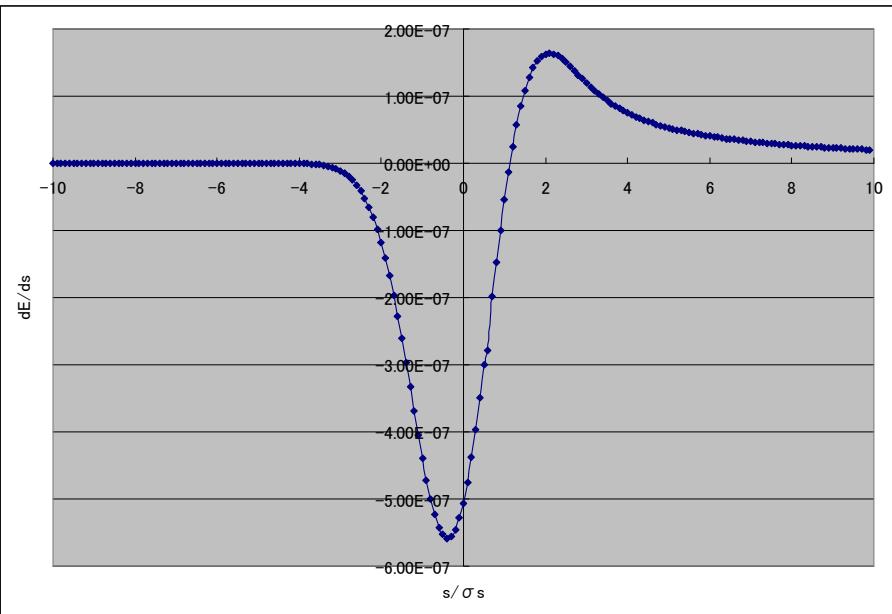
$$\gamma \Delta \epsilon_x = 2.9 \text{ mm} \cdot \text{mrad}$$



# CSR (ARC section)

$$\frac{dE(s)}{ds} = -\frac{1}{\sqrt{2\pi}} \frac{2qe}{\sqrt[3]{3R^2\sigma_z^4}} \int_{-\infty}^{\frac{z}{\sigma_z}} dx \frac{-xe^{-\frac{x^2}{2}}}{\sqrt[3]{\frac{z}{\sigma_z} - x}}$$

$$\sqrt{\langle \theta_{rad}^2 \rangle} \sim \frac{1}{\gamma} \sqrt[3]{\frac{3\sigma_z}{R}} \\ = 0.03 \text{ mrad}$$



Emittance growth is calculated similar to Dispersion

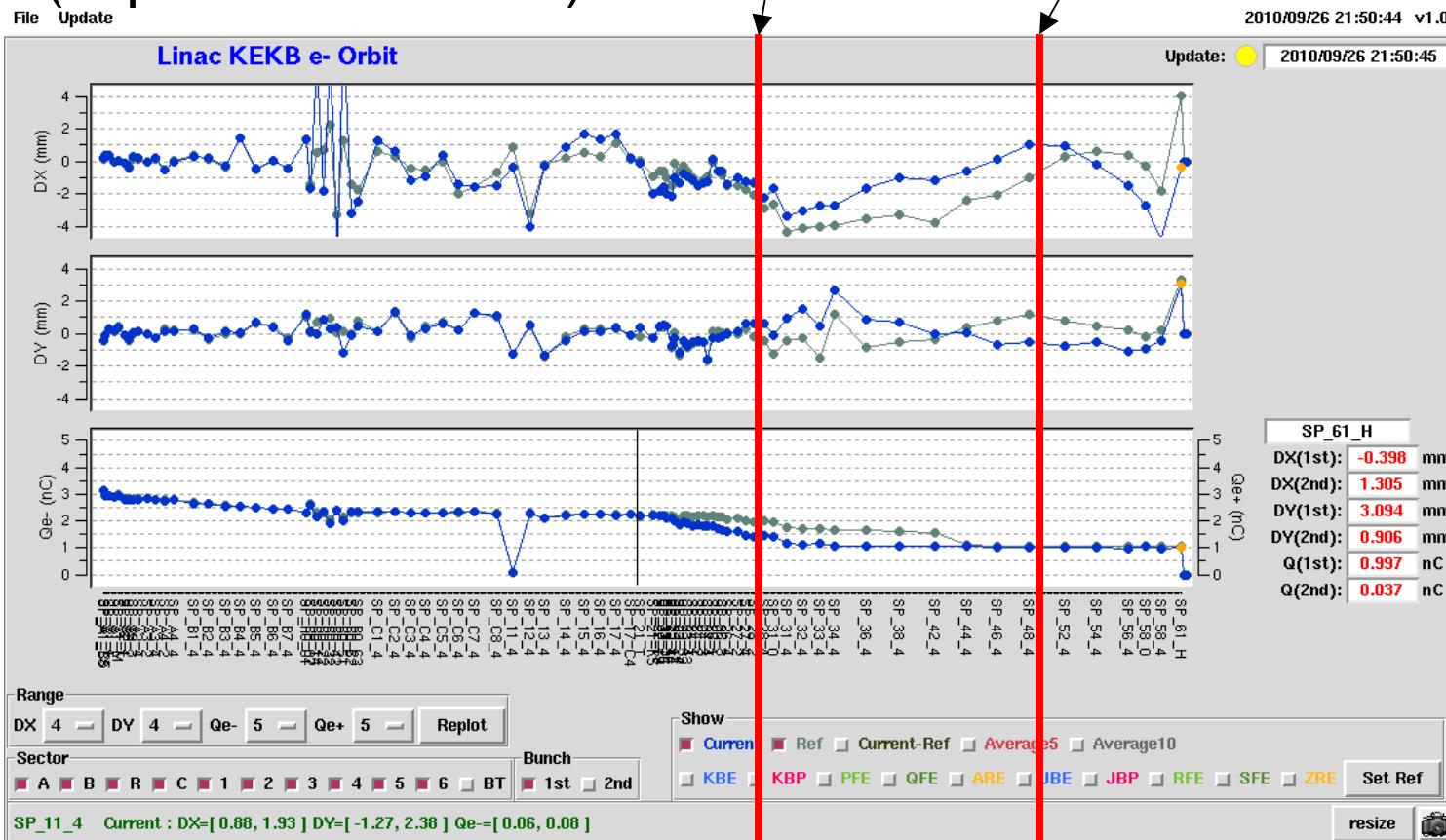
$$\varepsilon = \sqrt{\left( \varepsilon_0 \beta_x + \left( \frac{W \Delta E_{rms}}{E_0} \right)^2 \right) \left( \varepsilon_0 \gamma_x + \left( \frac{W' \Delta E_{rms}}{E_0} \right)^2 \right) - \left( \varepsilon_0 \alpha_x + W W' \left( \frac{\Delta E_{rms}}{E_0} \right)^2 \right)^2}$$

$= 1.2 \text{ nm}$

$$\gamma \varepsilon = 0.02 \text{ mm} \cdot \text{mrad}$$

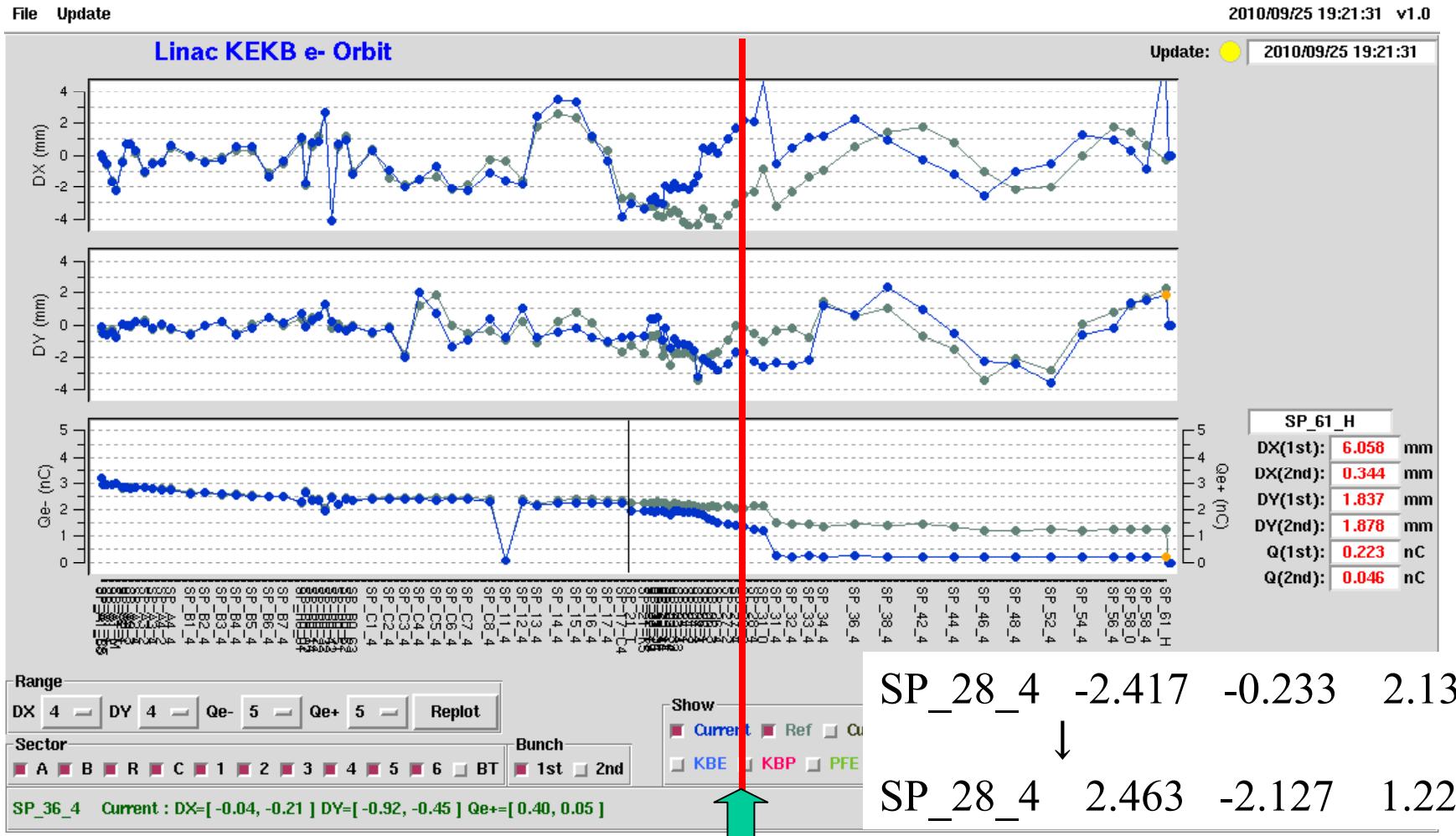
# Dispersion (change energy by ARC)

r0\_kbe 1.6092 → 1.6249 GeV  
 $(\Delta p = 0.0153 \text{ GeV})$



$$\delta = 0.1\% \text{ (8ps)}, \quad \eta = 210 \text{ mm} \quad \Rightarrow \frac{\gamma \eta(s)^2 \delta(s)^2}{2 \langle \beta \rangle} \sim 30 \text{ mm} \cdot \text{mrad}$$

# C-1 Standby での Dispersion



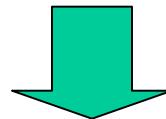
$$R_{16} = 5\text{mm} / (160\text{MeV}/1.6\text{GeV}) = 50 \text{ mm @ 2-8}$$

$$R_{36} = 2\text{mm} / (160\text{MeV}/1.6\text{GeV}) = 20 \text{ mm @ 2-8}$$

Same as r0\_kbe → J-ARC dispersion is not large.

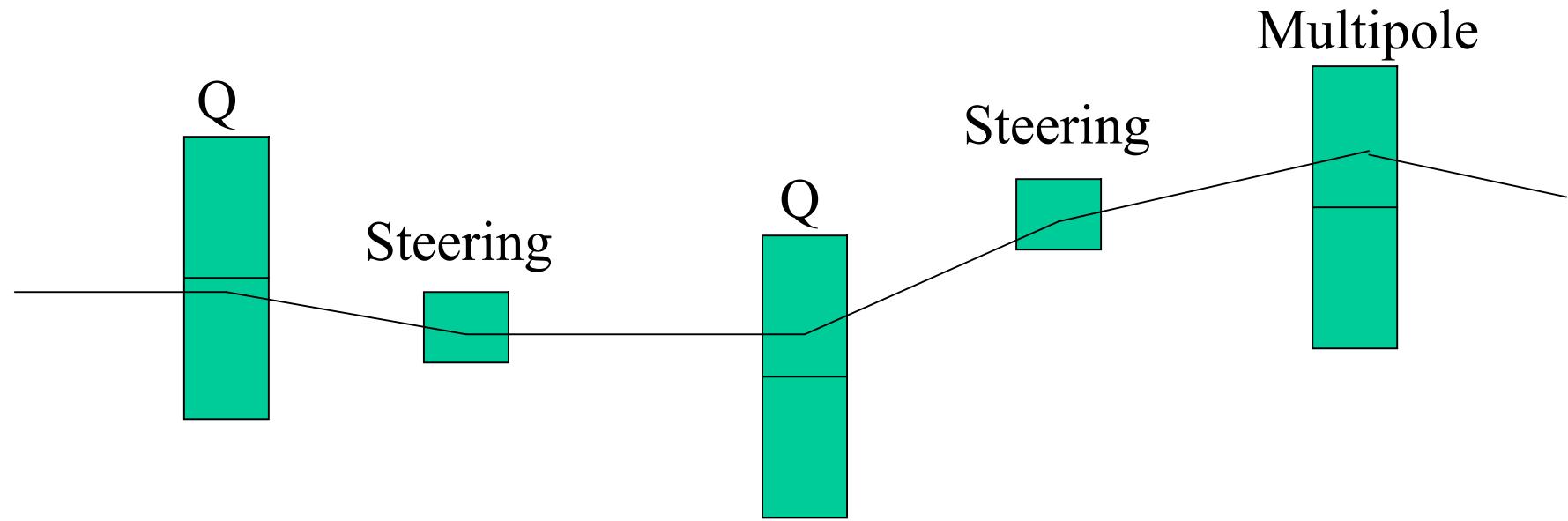
# Injector control software for SuperKEKB

- Multi-line / Multi-bunch : orbit & dispersion compensation
- Continuous measurement using study mode



- Response measurement for all magnets.
  - Paraxial & reference orbit measurement
  - Beam based alignment / Dispersion

# Paraxial and reference orbit



Transfer matrix

$$\begin{pmatrix} X \\ X' \\ \vdots \end{pmatrix} = M \begin{pmatrix} X \\ X' \\ \vdots \end{pmatrix} + \begin{pmatrix} O_0 \\ O'_0 \\ \vdots \end{pmatrix}, \quad \begin{pmatrix} X_0 \\ X'_0 \\ \vdots \end{pmatrix} = M_{ref} \begin{pmatrix} X_0 \\ X'_0 \\ \vdots \end{pmatrix} + \begin{pmatrix} x_0 \\ x'_0 \\ \vdots \end{pmatrix}$$

$$x = X - X_0, \quad x' = X' - X'_0$$

$$\begin{pmatrix} x \\ x' \\ \vdots \end{pmatrix} = M_{paraxial} \begin{pmatrix} x \\ x' \\ \vdots \end{pmatrix}$$

Paraxial

Reference matrix

↓ calculation

$$\begin{pmatrix} X \\ X' \\ \vdots \end{pmatrix} = M_{paraxial} \begin{pmatrix} x \\ x' \\ \vdots \end{pmatrix} + M_{ref} \begin{pmatrix} X_0 \\ X'_0 \\ \vdots \end{pmatrix} + \begin{pmatrix} x_0 \\ x'_0 \\ \vdots \end{pmatrix}$$

$$= M_{paraxial} \begin{pmatrix} X \\ X' \\ \vdots \end{pmatrix} + (M_{ref} - M_{paraxial}) \begin{pmatrix} X_0 \\ X'_0 \\ \vdots \end{pmatrix} + \begin{pmatrix} x_0 \\ x'_0 \\ \vdots \end{pmatrix}$$

# Emittance measurement

Recent modification of fitting program for the wire scanner

